

## Accepted Manuscript

Parasitic parameters of thin film structures created on flexible substrates in PVD process

Ewa Korzeniewska, Artur Szczęśny



PII: S0167-9317(18)30078-9  
DOI: [doi:10.1016/j.mee.2018.02.013](https://doi.org/10.1016/j.mee.2018.02.013)  
Reference: MEE 10740  
To appear in: *Microelectronic Engineering*  
Received date: 10 September 2017  
Revised date: 31 January 2018  
Accepted date: 15 February 2018

Please cite this article as: Ewa Korzeniewska, Artur Szczęśny , Parasitic parameters of thin film structures created on flexible substrates in PVD process. The address for the corresponding author was captured as affiliation for all authors. Please check if appropriate. Mee(2017), doi:[10.1016/j.mee.2018.02.013](https://doi.org/10.1016/j.mee.2018.02.013)

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.

Parasitic parameters of thin film structures created on flexible substrates in PVD process.

Ewa Korzeniewska, Artur Szczesny  
Institute of Electrical Engineering Systems, Lodz University of Technology, Lodz, Poland

{ewa.korzeniewska@p.lodz.pl, artur.szczesny@p.lodz.pl}

ACCEPTED MANUSCRIPT

Download English Version:

<https://daneshyari.com/en/article/6942491>

Download Persian Version:

<https://daneshyari.com/article/6942491>

[Daneshyari.com](https://daneshyari.com)